

Supplemental Material for
Electric control of Chern number in valley-polarized quantum anomalous Hall
insulators

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Supplementary Note 1: The underlying physical mechanism for spontaneous valley polarization in ferromagnetic semiconductors.

Due to the spontaneous valley polarization is induced by SOC with the intra-atomic interaction $\hat{L} \cdot \hat{S}$, we thus consider SOC as a perturbation, which can be written as $\hat{H}_{SOC}^0 + \hat{H}_{SOC}^1 = \lambda \hat{L} \cdot \hat{S}$.^{1,2} Here, \hat{L} and \hat{S} are orbital angular moment and spin angular moment, respectively.

$$\hat{H}_{SOC}^0 = \lambda \mathcal{S}_z (\mathcal{L}_z \cos \theta + \frac{1}{2} \mathcal{L}_+ e^{-i\phi} \sin \theta + \frac{1}{2} \mathcal{L}_- e^{+i\phi} \sin \theta),$$
$$\hat{H}_{SOC}^1 = \frac{\lambda}{2} (\mathcal{S}_+ + \mathcal{S}_-) (-\mathcal{L}_z \sin \theta + \frac{1}{2} \mathcal{L}_+ e^{-i\phi} \cos \theta + \frac{1}{2} \mathcal{L}_- e^{+i\phi} \cos \theta)$$

\hat{H}_{SOC}^0 is the Hamiltonian that describes the interaction between the same spin states, while \hat{H}_{SOC}^1 indicates the interaction between opposite spin states. Given that the K (-K) valleys in valence bands and conduction bands hold identical spin near Fermi level, the effective Hamiltonian of SOC can be written as:

$$\hat{H}_{SOC} = \lambda \mathcal{S}_z (\mathcal{L}_z \cos \theta + \frac{1}{2} \mathcal{L}_+ e^{-i\phi} \sin \theta + \frac{1}{2} \mathcal{L}_- e^{+i\phi} \sin \theta)$$

where θ and ϕ are the spin orientations. When the magnetization orientation is

perpendicular to the plane ($\theta = 0^\circ$), the Hamiltonian can be simplified as: $\hat{H}_{SOC} = \lambda \hat{S}_z \hat{L}_z$. Due to the orbital composition of K (-K) valleys in vicinity of Fermi level is composed of $d_{x^2-y^2}/d_{xy}$ of Cr atoms We thus adopt

$$|\phi_{c/v}^\tau\rangle = \frac{1}{\sqrt{2}} \left(|d_{x^2-y^2}\rangle + i\tau |d_{xy}\rangle \right)$$

as orbital basis, where $\tau = \pm 1$ represent valley index, the subscript $c(v)$ indicates conduction (valence) band. Under the influence of SOC, the energy level of K/K' valleys in conduction and valence band can be described as follows:

$$E_c^\tau = \langle \phi_c^\tau | \hat{H}_{soc} | \phi_c^\tau \rangle, \quad E_v^\tau = \langle \phi_v^\tau | \hat{H}_{soc} | \phi_v^\tau \rangle$$

It is well established that $\hat{L}_z |d_{x^2-y^2}\rangle = 2i |d_{xy}\rangle$, $\hat{L}_z |d_{xy}\rangle = -2i |d_{x^2-y^2}\rangle$. And the valley polarization of CBM and VBM are

$$E_{c/v}^K - E_{c/v}^{-K} = i \langle d_{x^2-y^2} | \hat{H}_{SOC} | d_{xy} \rangle - i \langle d_{xy} | \hat{H}_{SOC} | d_{x^2-y^2} \rangle = 4\alpha,$$

$\alpha = \lambda \langle d_{x^2-y^2} | \hat{S}_z | d_{x^2-y^2} \rangle$. Hence, the valley polarization can occur in both CBM and VBM. Here, we observe that a difference in the values of valley polarization between the CBM and VBM, which mainly arises from the warped band structure caused by band inversion at K valley.

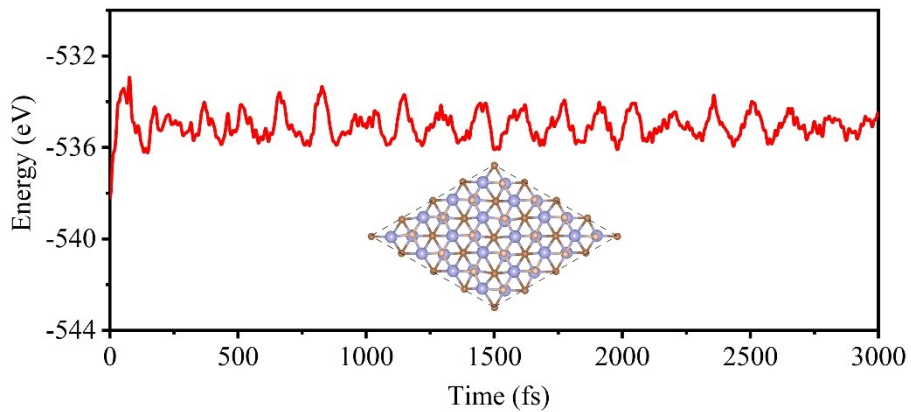


FIG. S1. Fluctuations of the total energy of Cr_2COH monolayer at 300 K. Inset is the snapshot taken from the end of the MD simulation.

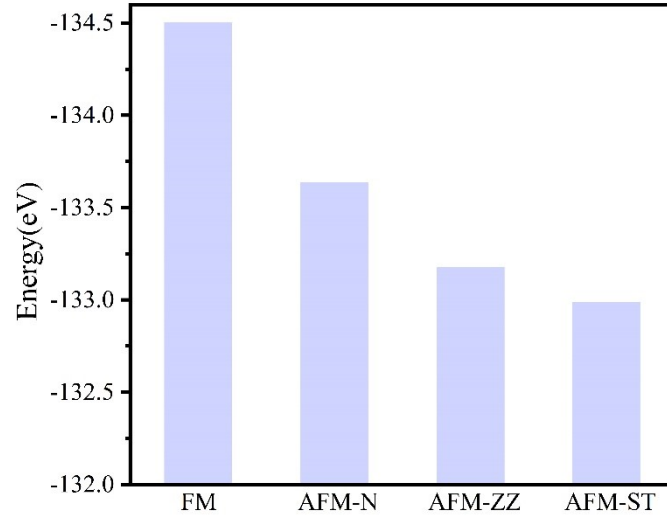


FIG. S2. Total energies of FM and various AFM configurations for the Cr_2COH monolayer.

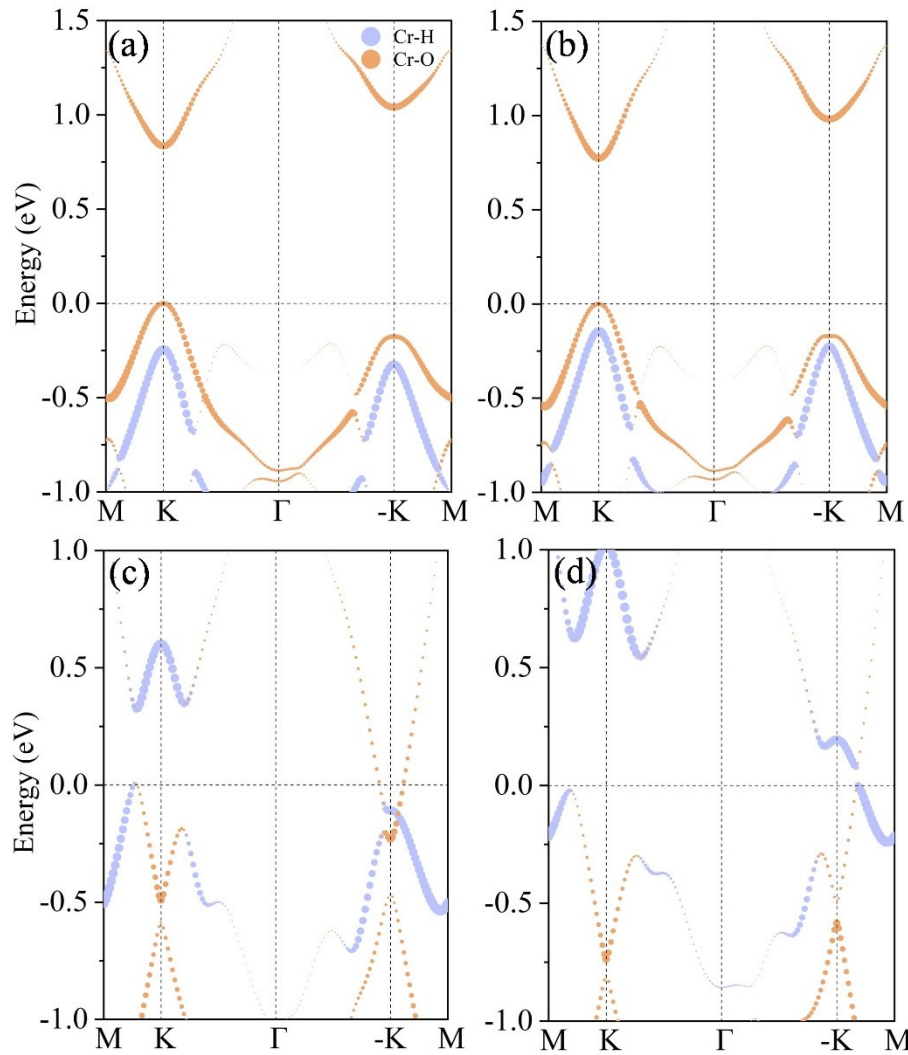


FIG. S3. The d -orbitals-project band structure of Cr_2COH monolayer under electric

field of (a) -0.2 V/\AA , (b) -0.15 V/\AA , (c) 0.15 V/\AA and (d) 0.2 V/\AA .

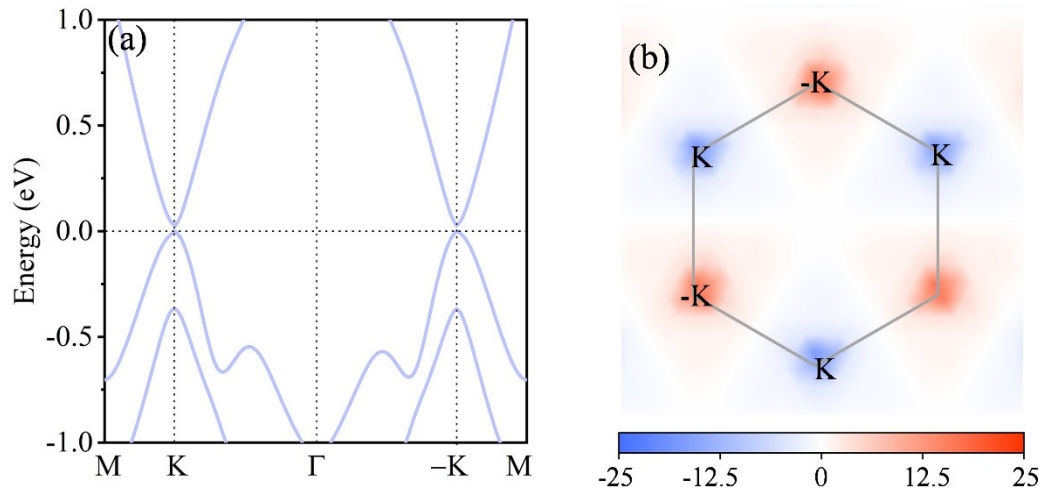


FIG. S4. (a) Band structures and Berry curvature of Cr_2COH monolayer with in-plane magnetization orientation when considering SOC.

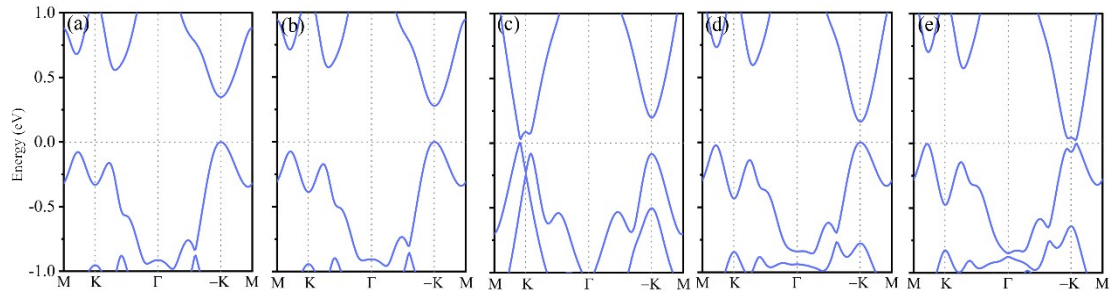


FIG. S5. Band structures with considering SOC under biaxial strain of (a) -2% , (b) -1% , (c) 0% , (d) 1% and (e) 2% .

1. Dai, D.; Xiang, H.; and Whangbo, M. H. *J. Comput. Chem.* **29**, 2187 (2008).
2. Whang, M.; Gordon, E.; Xiang, H.; Koo, H.; Lee, C. *Acc. Chem. Res.* **48**, 3080 (2015).